SN 10/624,855 Docket No. S-100,564 In Response to Office Action dated January 17, 2006 AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

LISTING OF CLAIMS:

Claim 1. (withdrawn) A composite structure for subsequent growth epitaxial film layer thereon comprising:

a base substrate; and,

a buffer layer of $SrTi_xRu_{1-x}O_3$ where 0 < x < 1 thereon said base substrate.

Claim 2. (withdrawn) The composite structure of claim 1 further including at least one layer of a second buffer material upon the layer of $SrTi_xRu_{1-x}O_3$ where 0 < x < 1.

Claim 3. (withdrawn) The composite structure of claim 1 wherein said base substrate is of a material selected from the group consisting of polycrystalline metals, polycrystalline ceramics, single crystal lanthanum aluminum oxide, single crystal aluminum oxide, single crystal magnesium oxide, silica and glass.

Claim 4. (withdrawn) The composite structure of claim 1 wherein said base substrate is of a material selected from the group consisting of polycrystalline ceramics, single crystal lanthanum aluminum oxide, single crystal aluminum oxide, single crystal magnesium oxide, silica and glass.

Claim 5. (withdrawn) The composite structure of claim 1 further including at least one layer of a second buffer material upon the layer of $SrTi_xRu_{1-x}O_3$ where 0 < x < 1.

Claim 6. (withdrawn) A composite structure for subsequent growth of a epitaxial film layer thereon comprising:

a base metallic substrate having a layer of magesium oxide thereon; and a buffer layer of $SrTi_xRu_{1-x}O_3$ where $0 < x \le 1$ thereon said layer of magesium oxide.

Claim 7. (withdrawn) The composite structure of claim 6 wherein said buffer layer is strontium titanate.

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Claim 8. (withdrawn) The composite structure of claim 6 wherein said layer of magesium oxide is deposited by ion-beam-assisted deposition.

Claim 9. (withdrawn) The composite structure of claim 6 wherein said buffer layer is a mixture of strontium titanate and strontium ruthenate.

Claim 10. (withdrawn) The composite structure of claim 6 further including at least one layer of a second buffer material upon the layer of $SrTi_xRu_{1-x}O_3$ where $0 < x \le 1$.

Claim 11. (withdrawn) The composite structure of claim 10 wherein the second buffer material is cerium oxide.

Claim 12. (withdrawn) The composite structure of claim 6 wherein the high quality epitaxial thin film is an epitaxial high temperature superconducting thin film.

Claim 13. (withdrawn) The composite structure of claim 6 said mixture of strontium titanate and strontium ruthenate includes about 50 percent by weight strontium ruthenate.

Claim 14. (currently amended) A superconducting article comprising: a base metallic substrate including one or more intermediate layers; a layer of magnesium oxide deposited by ion-beam-assisted deposition thereon said one or more intermediate layers of said base metallic substrate;

a buffer layer of <u>a single phase</u> $SrTi_xRu_{1-x}O_3$ where 0 < x < 1 thereon said layer of magnesium oxide; and,

a top-layer of a high temperature superconducting material upon the buffer layer of $SrTi_xRu_{1-x}O_3$ where 0 < x < 1.

Claim 15. (original) The superconducting article of claim 14 wherein the high temperature superconducting material is YBCO.

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Claim 16. (previously amended) The superconducting article of claim 15 further including a layer of a second buffer layer between said layer of SrTi_xRu_{1-x}O₃ where 0 < x < 1 and said top-layer of a high temperature superconducting material.

Claim 17. (original) The superconducting article of claim 16 wherein the second buffer layer is cerium oxide.

Claim 18. (currently amended) The A superconducting article of claim 14 wherein said buffer layer is strontium titanate comprising:

<u>a base metallic substrate including one or more intermediate layers; a layer of</u>
<u>magnesium oxide deposited by ion-beam-assisted deposition thereon said one or more</u>
intermediate layers of said base metallic substrate;

a buffer layer of strontium titanate thereon said layer of magnesium oxide; and, a top-layer of a high temperature superconducting material of a thickness of from about 10,000 angstroms to about 20,000 angstroms upon the buffer layer of strontium titanate.

Claim 19. (cancelled)

Claim 20. (currently amended) A process of preparing a superconducting article comprising:

depositing a layer of magnesium oxide by ion-beam-assisted deposition upon a base metallic substrate including one or more intermediate layers thereon;

depositing a buffer layer of <u>single phase</u> $SrTi_xRu_{1-x}O_3$ where 0 < x < 1 thereon said layer of magnesium oxide a deposition temperatures between about $800^{\circ}C$ and $825^{\circ}C$; and, depositing a top-layer of a high temperature superconducting material upon the buffer layer of $SrTi_xRu_{1-x}O_3$ where 0 < x < 1.